REMARKS

This Amendment amends claim 14 in response to the Notice of Non-Compliant Amendment dated May 7, 2002. Claims 1-22 are pending. Claims 1-12 have been withdrawn from prosecution. Of the remaining claim, claims 14 is independent.

Attached hereto is a marked-up version of the changes made to the claim by the current Amendment. The attached page is captioned "**VERSIONS WITH MARKINGS TO SHOW CHANGES MADE**".

III. FORMAL MATTERS AND CONCLUSION

In view of the foregoing amendments and remarks, Applicants respectfully submit that the Application is in condition for allowance. Applicants respectfully request prompt reconsideration and allowance.

Should the Examiner believe that anything further is desirable to place the application into condition for allowance, Applicants invite the Examiner to contact the undersigned attorney at the telephone number listed below.

The Commissioner is hereby authorized to charge any deficiency in fees or to credit any overpayment in fees to Attorney's Deposit Account No. 50-0481.

Respectfully Submitted,

Date: 5/13/02

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VERSION WITH MARKINGS TO SHOW CHANGES MADE

In the claims:

Please amend claim 14 as follows:

14. (Amended) A method for producing a transparent laminate comprising [steps of]:

preparing a transparent substrate;

depositing a high-refractive-index transparent thin film by a vacuum dry process;

depositing a silver transparent conductive thin film by a vacuum dry process;

repeating [said steps for] forming of the high-refractive-index transparent thin film and the silver transparent conductive thin film at least three [or four] times to thereby form at least three [or four] combination thin-film layers of the high-refractive-index transparent thin film and the silver transparent conductive thin film successively laminated on a surface of said transparent substrate; and

depositing another high-refractive-index transparent thin film on a surface of said combination thin-film layer by the vacuum dry process,

wherein, when said silver transparent conductive thin films are deposited by the vacuum dry process, temperature T (K) of said transparent substrate at the time of the deposition of said films is set to be in a range $340 \leq T \leq 390$, and deposition rate R (nm/sec) of said silver transparent conductive thin films is set to be $R = (1/40)x(T-300)\pm 0.5$.